



High Voltage Trench Schottky Diode

FEATURES

- Trench MOS Schottky technology
- Die in 6" Wafer Form
- 80V, 15A*
- $V_F=0.58V$ (typ.)***

Electrical Characteristics (T_j=25°C)

Parameter	Description	Min.	Typ.	Max.	Unit	Test Condition
V _{RRM}	Maximum repetitive peak reverse voltage	80	91	—	V	I _R =500μA
V _F	Static Forward Voltage	—	0.37	0.42	V	I _F =1A
		—	0.50	0.54	V	I _F =8A
		—	0.58	0.63	V	I _F =15A
I _R ***	Cathode-To-Anode Leakage Current	—	16	50	μA	V _R =80V
T _J , T _{STG}	Operating and Storage Temperature Range	-55°C to 150°C Max				
*** Pulse width < 300 uS, Duty cycle < 2%						

Mechanical Data

Die Size	2592×2592	μm ²	CHIP DRAWING (Scribe Line is Excluded)	
Source Pad Size	1800 × 1800	μm ²		
Scribe Line Size	60	μm		
Wafer Diameter	6	in		
Wafer Thickness	250	μm		
Estimated Gross Die	2372(Yield>97%)			
Anode Metal Thickness	Al\Ti\ Ni\Ag (2.8um\0.1um\0.2um\1.8um)			
Cathode Metal Thickness	Ti\Ni\Ag (0.2um\0.3um\2um)			
Recommended Storage Environment	Store in original container, in dry nitrogen, < 6 months at an ambient temperature of 23°C±3°C >			

* Electrical characteristics are reported for the reference packaged part (TO-220) and can not be guaranteed in die sales form.

** Electrical characteristics are reported for the bare die. Variations in customer packaging materials, dimensions and processes may affect parametric performance.